

Cite this: *Chem. Commun.*, 2015, 51, 714Received 24th September 2014,
Accepted 11th November 2014

DOI: 10.1039/c4cc07554d

www.rsc.org/chemcomm

Formation of a quasi-solid structure by intercalated noble gas atoms in pores of Cu^I-MFU-4l metal–organic framework†

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The primary adsorption sites for Kr and Xe within the large-pore metal–organic framework Cu^I-MFU-4l have been investigated by high-resolution synchrotron powder diffraction, revealing an enormous number of adsorption sites: in total, 10 crystallographically different positions for Xe and 8 positions for Kr were localized, the first five of which are located near metal atoms and the organic linker, and the remaining sites form a second adsorption layer in the pores.

Although noble gases have a high potential in industrial applications (e.g. fluorescent light lamps, thermal insulation, excimer lasers, ionization chambers, general inhalation anesthetics), their practical use is restricted by their high costs due to the energetically expensive procedure of their separation. A mixture of krypton and xenon is obtained by cryogenic distillation of air, which initially contains only 1.14 ppm of krypton and 0.087 ppm of xenon.¹ Further separation of noble gases from their mixture requires additional distillation. Development of porous metal–organic frameworks (MOFs) for adsorption-enhanced separation of noble gases can considerably decrease costs and extend practical applications. Another promising application of MOFs is the storage and separation of radioactive noble gases. The gaseous products from nuclear reactors, nuclear fuel reprocessing plants, and from the production of medical isotopes contain significant amounts of radioactive krypton and xenon, which are difficult to separate and to confine because they are chemically inert and relatively insoluble in water.¹ Their storage and transportation can be substantially improved by using highly selective MOFs with good storage capacity.

The development of MOFs with specific adsorption properties requires deep insight into the factors controlling noble gas adsorption, primarily through experimental investigations of the interaction between adsorbent and noble gas atoms. It is still largely unclear, how

the MOF structure and metal sites influence the noble gas adsorption properties. Despite the fact that the major adsorption sites and their binding energies are the key features of a system that determines its adsorption properties at a given temperature and pressure, only four X-ray or neutron diffraction studies targeting at the adsorption sites of noble gases in MOFs were performed so far.^{2–5} On the other hand, the possibility of using MOFs for noble gas storage and separation caused extensive theoretical investigations of key factors determining noble gas adsorption and separation over last a few years,⁶ as well as numerous experimental Xe and Kr adsorption studies.^{4,5,7,8}

The present communication reports the results of the structural investigation on the guest noble gases Xe and Kr in Cu^I-MFU-4l, Cu_{2.13}Zn_{2.87}Cl_{0.52}(HCOO)_{1.35}(BTDD)₃; H₂-BTDD = (bis(1*H*-1,2,3-triazolo-[4,5-*b*],[4,5-*i*])dibenzo-[1,4]-dioxin), supported by adsorption and thermal desorption measurements. Cu^I-MFU-4l is isostructural to MFU-4l, the latter constructed from [Zn₅Cl₄]⁶⁺ secondary building units (SBUs) and bis-triazolate BTDD²⁻ ligands.⁹ MFU-4l contains two differently sized cavities alternating in three dimensions, which differ by the orientation of chloride ligands and by the relative orientations of the organic linkers (Fig. 1). The Cu atoms in Cu^I-MFU-4l randomly substitute ~50% of the peripheral Zn atoms of the [Zn₅Cl₄]⁶⁺ SBUs.¹⁰ Only approx. 30% of the peripheral zinc ions are coordinated by chloride anions, whereas the major part in the Zn ions are coordinated by formate ligands. Three-fold coordinated Cu^I ions represent unsaturated open metal sites after evacuation of Cu^I-MFU-4l. Cu^I-MFU-4l possesses many unique adsorption properties, including extremely strong and reversible chemisorption of H₂, N₂, and C₂H₄.¹⁰ Additionally to its high thermal stability, Cu^I-MFU-4l is stable in air and after prolonged evacuation, a key factor for technical applications.

In this communication we report on the unique adsorption of noble gases Xe and Kr by exceptional thermally and chemically stable Cu^I-MFU-4l, making it a promising candidate for industrial noble gas storage and separation.

X-ray powder diffraction (XRPD) measurements of Xe adsorption in Cu^I-MFU-4l were performed at 250 K and 170 K, of Kr adsorption at 250 K, 170 K, and 130 K at different pressures (5 kPa, 10 kPa, 25 kPa, 50 kPa, and 100 kPa) at the high-resolution diffractometer

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† Electronic supplementary information (ESI) available: XRPD, crystallographic data, and adsorption/desorption measurements. See DOI: 10.1039/c4cc07554d



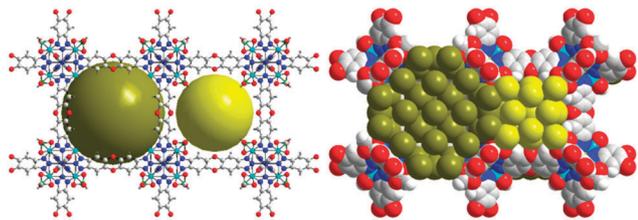


Fig. 1 (left) Crystal structure of MFU-4l with two types of alternating cavities: large and small; (right) Cu^I-MFU-4l with all 10 positions of Xe occupied (van der Waals radii for all atoms).

ID31 at ESRF (Grenoble).¹¹ Samples were evacuated *in situ* at 180 °C before gas loading, and validated by Rietveld refinement.¹² Then they were cooled down to room temperature and exposed to Xe or Kr gas.

The noble gas adsorption behaviour of Cu^I-MFU-4l was investigated under various pressures and temperatures and revealed the formation of a unique quasi-solid Xe and Kr structures in the cavities at temperatures above the corresponding boiling temperatures for Xe (5 K above boiling temperature) and Kr (10 K above boiling temperature).

With decreasing temperature and increasing gas pressure, up to 10 positions for Xe and up to 8 positions for Kr were located. There are five adsorption sites, which are closest to the framework, while the remaining sites form a second adsorption layer within the pores (Fig. 2). The main adsorption site I for both Xe and Kr atoms in Cu^I-MFU-4l is the same as for MFU-4l³ (Fig. 2, I). It is located in the center of the three faces of ZnN₃Cl (metal site) at approximately the same distances from the central (octahedral) and peripheral (tetrahedral) metal atoms of SBUs, and also close to the nitrogen atoms, which create a steric barrier between noble gas atoms and metal atoms. This adsorption site is the closest to the framework and provides the possibility to interact with the large part of framework for adsorbed noble gas atoms. The second adsorption site II interacts with a peripheral outer metal atom and formate ligands (coordinated statistically disordered Zn atoms, not shown in Fig. 2) and is close to adsorption site I at low pressures and high temperature, representing statistical disorder of adsorption site I, but moving away from the central metal atom and interacting only with the peripheral metal atom and framework atoms upon increasing the pressure (Fig. 2, II). Both adsorption sites I and II are located in the large cavities. The adsorption site III interacts with the unsaturated statistically distributed trigonal pyramidal Cu^I open metal sites in the small cavities as well as with framework atoms (Fig. 2, III). The adsorption site IV is located near the center of the C₄O₂ 1,4-dioxane ring of the organic linker (Fig. 2, IV). The adsorption site V is disordered near oxygen atoms of the organic linker (Fig. 2, V). Oxygen atoms from carbon–oxygen bonds were found previously to be quite strong adsorption sites for argon,² for Kr and for Xe.⁵ Further increasing of pressure (decreasing of temperature) results in the formation of a second adsorption layer in the large pores (Fig. 2, VI, VII, VIII), which consists of 3 different positions similar for both, Xe and Kr atoms. Two peripheral atomic positions of this second adsorption layer form the remarkable tungsten-type coordination around a central third position. The formation of a

second adsorption layer in the small pores (two adsorption positions) was observed only for Xe atoms at $T = 170$ K and a pressure above 25 kPa (corresponding to 0.2 relative pressure), showing that small and large pores are not equivalent for noble gas adsorption (Fig. 2, IX, X). The filling of accessible voids in the small pores is responsible for the weak inflection in the Xe adsorption isotherms (Fig. 3, middle). It can be seen that the main adsorption step for Xe is unusually steep and suggests highly selective filling of large pores (approx. 85% of total pore volume which corresponds to the data obtained from XRPD measurements). This is probably the reason, why two separated steps are observed in the case of Xe adsorption. Kr, in contrast, shows only one adsorption step with rather usual shape (Fig. 3, top). In the case of Kr adsorption at 130 K, the small pore remains empty even at quite high pressure (100 kPa, corresponding to 0.5 relative pressure, Fig. 3, top). This fact looks more surprising taking into account the smaller kinetic radius of Kr atoms and can be explained by larger difference between the actual temperature of the measurement (130 K) and the boiling temperature of Kr (120 K) in contrast to Xe (170 K measurement temperature and 165 K boiling temperature). At highest loadings the large cavity adsorbs *ca.* 55 atoms of Xe and *ca.* 70 atoms of Kr in 83 available positions, providing a very dense packing of adsorbed noble gas atoms. Almost complete filling of large (and small) cavities of Cu^I-MFU-4l results into formation of quasi-solid structure by Kr and Xe atoms inside the cavities above their boiling temperature – a phenomenon, which to the best of our knowledge has not been reported before. The apparent increase of the freezing point for Xe and Kr is related to strong van der Waals interaction with the framework atoms.

For both Xe and Kr atoms, the coordinatively unsaturated Cu^I sites from the peripheral part of the SBU are not the first occupied adsorption sites, and their filling starts only after the major adsorption site in the center of triangular faces of the ZnN₃Cl tetrahedron is filled. It can be related with preferential filling of large cavities in Cu^I-MFU-4l, while Cu atoms are located in small cavities. On the other hand, the coordinatively unsaturated Cu^{II} sites in large cavities of HKUST-1 are not coordinated by noble gas atoms even at the highest pressures applied in these experiments.⁴ In contrast, the coordinatively unsaturated Ni^{II} and Mg^{II} sites in CPO-27-Ni and CPO-27-Mg are (one of) the primary adsorption sites.⁵ Thus, the adsorption of noble gases critically depends on the type of metal ion in the SBU of the MOFs. This interesting phenomenon requires further structural investigation.

From the adsorption isotherms at different temperatures follows the high Xe/Kr selectivity of 8.1 at 250 K and 6.3 at 280 K, which correlates with selectivity from structural investigation of single gas adsorption. The large selectivity of Cu^I-MFU-4l is based on enhanced xenon–framework interactions in comparison with the krypton–framework interactions, which relates to the higher polarizability of Xe atom, as well as to stronger interactions between adsorbed Xe atoms. The latter follows from the variation of the lattice parameters at constant temperature: the unit cell is contracting upon Xe adsorption, and the only observed case of expansion is connected with entering Xe into small pores at 170 K, 25 kPa (as described in the ESI,[†] Tables S4 and S5). The corresponding contraction of the unit cell upon Kr adsorption is much smaller and is changing to



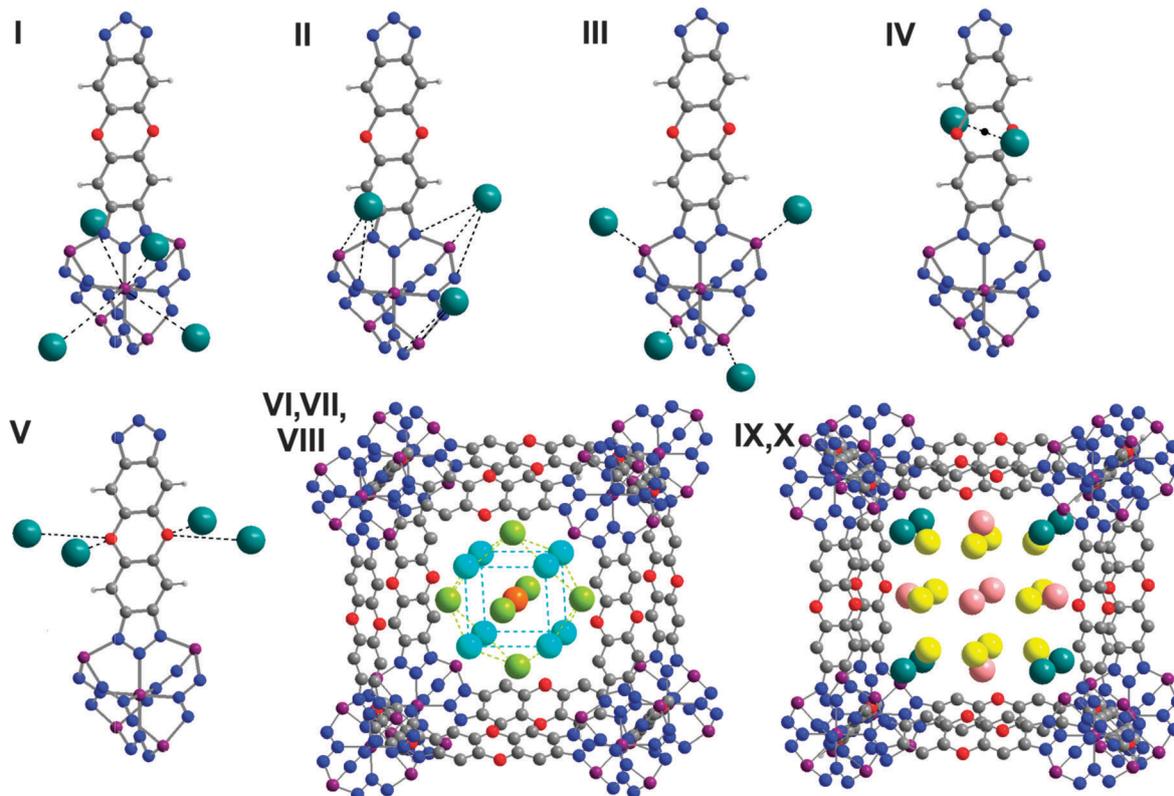


Fig. 2 Ten symmetry-independent adsorption sites occupied by Xe atoms (shown by large spheres) in the pores of Cu^{I} -MFU-4l. Eight of these sites are also occupied by Kr atoms. These include three sites (I, II, and III) associated with secondary building unit, two sites (IV and V) associated with the organic linker, and five sites forming second adsorption layer within large (VI, VII, VIII) pores (three adsorption sites for both Xe and Kr) and small (IX, X) pores (two adsorption sites only for Xe, and adsorption site III for both, Xe and Kr). Framework atoms: carbon (gray), oxygen (red), nitrogen (blue), copper/zinc (violet).

expansion at high pressure due to the repulsion between adsorbed Kr atoms.

The isosteric heats of Xe and Kr adsorption in Cu^{I} -MFU-4l, determined from the adsorption isotherms (as described in the ESI,[†] Table S3), are nearly identical (within the experimental uncertainty of $\text{ca. } \pm 0.5 \text{ kJ mol}^{-1}$) with the corresponding values determined previously for MFU-4l⁸ (Fig. 3, bottom). Therefore, no considerable chemical interaction between Cu^{I} centers and Xe or Kr atoms takes place. This confirms the results of XRPD measurements, which have shown that unsaturated Cu^{I} centers are not the strongest adsorption sites for Xe or Kr. Since van der Waals interaction between polarizable adsorbed noble gas atoms and the polarizable host framework is the main factor responsible for adsorption of noble gases, the initial adsorption in position I (having the largest geometrical area of contacts between adsorbed atom and framework) is responsible for slightly increased isosteric heat of adsorption at low-pressures (Fig. 3). The remaining four positions of the first adsorption layer have very similar binding strength to the framework, resulting into constant isosteric heat upon their filling. Low-temperature adsorption isotherms show, that for Xe at 170 K the pores are completely filled already at $\text{ca. } 25 \text{ kPa}$ pressure (the adsorbed volume is nearly the same as at 165 K, the normal boiling point of Xe). In the case of Kr, in contrast, the complete pore filling can only be achieved at its boiling point (120 K), whereas at 130 K the small pores are not filled

even at 95 kPa pressure (Fig. 3). These observations are also in agreement with XRPD measurements.

Thermal desorption spectroscopy (TDS) measurements show two desorption maxima for Xe as well as for Kr (as described in the ESI,[†] Fig. S8 and S9). The desorption maximum at higher temperature can be attributed to the more strongly bound first adsorption layer, whereas the more weakly bound second adsorption layer desorbs already at lower temperature. In Cu^{I} -MFU-4l the noble gas desorption takes place in nearly the same temperature region as in MFU-4l⁸ showing no increased interaction of noble gases by Cu^{I} centers.

The results of Xe and Kr adsorption on Cu^{I} -MFU-4l are consistent with the adsorption behavior of the lighter argon atoms in MOF-5.² In total, 8 different adsorption sites of argon in MOF-5 were found. Large and small cavities of MOF-5 were also found to be not equivalent for noble gas adsorption, showing preferable filling of large cavities, and only one argon atom was located in the small cavity. This investigation is in contrast to the noble gas adsorption by HKUST-1,⁴ where all adsorption sites are associated with small cavities, and large cavities remain empty.

In summary, we report a detailed high-resolution XRPD study of Xe and Kr adsorption in cavities of Cu^{I} -MFU-4l, showing the formation of an almost “solid” structure of intercalated atoms inside the cavities. This quasi-solid structure of noble gas atoms



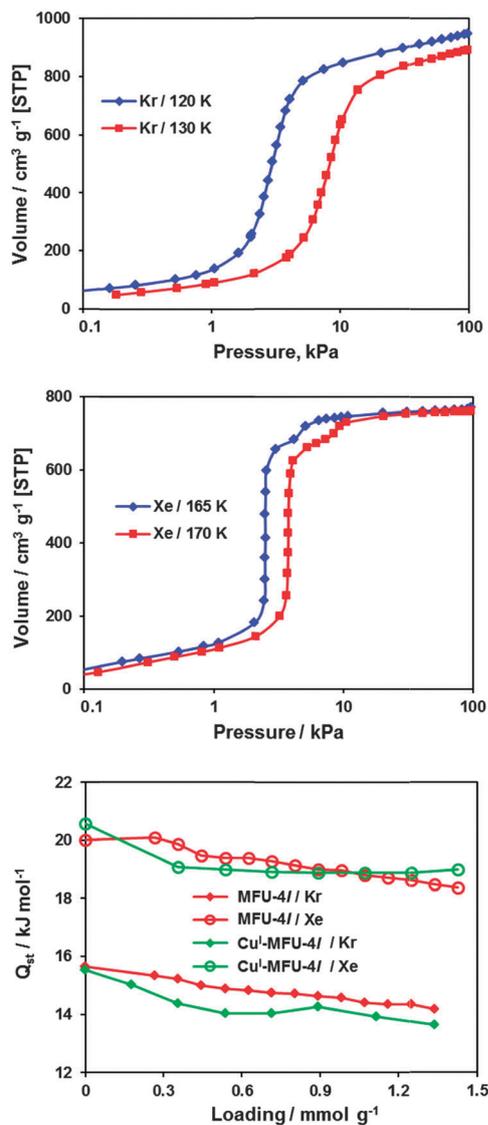


Fig. 3 Saturation adsorption isotherms for Kr (top) and Xe (middle) in Cu^{I} -MFU-4l in semilogarithmic scale, and dependencies of the isosteric heats of adsorption on loading for Kr and Xe in Cu^{I} -MFU-4l in comparison to MFU-4l⁸ (bottom).

in cavities is stabilized above the boiling temperatures of the corresponding gases by van der Waals interaction. The presence of multiple adsorption sites with similar binding energies in Cu^{I} -MFU-4l provides a great opportunity for Xe and Kr storage and separation due to homogeneous adsorption. The identification of the role of open metal sites and small cavities in the noble gas adsorption can be considered as a base for further engineering of MOFs in order to achieve maximal storage capacity and selectivity.

Support with synchrotron measurements at ESRF, ID31 (proposals ch3737, ch3878) to Dr C. Drathen (ESRF, Grenoble), Mr F. Adams and Mr T. Runcevski (Max Planck Institute for Solid State Research, Stuttgart) is gratefully acknowledged. Partial funding by the German

Research Foundation DFG within the priority program SPP 1362 is gratefully acknowledged.

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